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APPLICATION NO. FILING DATE FIRST NAMED INVENTOR ATTORNEY DOCKET NO. CONFIRMATION NO. 10/620,832 07/16/2003 10114-015 Esin Gulari 1263 EXAMINER 03/03/2006 Lawrence G. Almeda SANDERS, KRIELLION ANTIONETTE **BRINKS HOFER GILSON & LIONE** ART UNIT PAPER NUMBER P.O. Box 10395 Chicago, IL 60610

DATE MAILED: 03/03/2006

Please find below and/or attached an Office communication concerning this application or proceeding.

		1.)
	Application No.	Applicant(s)	
Office Action Summary	10/620,832	GULARI ET AL.	
	Examiner	Art Unit	
	Kriellion A. Sanders	1714	
The MAILING DATE of this communication a Period for Reply	appears on the cover sheet with	the correspondence address	
A SHORTENED STATUTORY PERIOD FOR REF WHICHEVER IS LONGER, FROM THE MAILING - Extensions of time may be available under the provisions of 37 CFR after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory perion. - Failure to reply within the set or extended period for reply will, by stat Any reply received by the Office later than three months after the may earned patent term adjustment. See 37 CFR 1.704(b).	DATE OF THIS COMMUNICA 1.136(a). In no event, however, may a reply od will apply and will expire SIX (6) MONTHS tute, cause the application to become ABAN	TION. be timely filed from the mailing date of this communication. DONED (35 U.S.C. § 133).	
Status			
3) Since this application is in condition for allow	his action is non-final. vance except for formal matters	•	
closed in accordance with the practice unde	r <i>Ex par</i> te Quayle, 1935 C.D. 1	1, 453 O.G. 213.	
Disposition of Claims			
4) ☐ Claim(s) 1-16 is/are pending in the application 4a) Of the above claim(s) is/are withd 5) ☐ Claim(s) is/are allowed. 6) ☐ Claim(s) 1-16 is/are rejected. 7) ☐ Claim(s) is/are objected to. 8) ☐ Claim(s) are subject to restriction and	rawn from consideration.		
Application Papers			
9) The specification is objected to by the Exami 10) The drawing(s) filed on is/are: a) a Applicant may not request that any objection to the Replacement drawing sheet(s) including the corn 11) The oath or declaration is objected to by the	ccepted or b) objected to by he drawing(s) be held in abeyance ection is required if the drawing(s)	See 37 CFR 1.85(a). is objected to. See 37 CFR 1.121(d).	
Priority under 35 U.S.C. § 119			
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority docume 2. Certified copies of the priority docume 3. Copies of the certified copies of the priority application from the International Bure * See the attached detailed Office action for a life.	ents have been received. ents have been received in App riority documents have been re eau (PCT Rule 17.2(a)).	lication No ceived in this National Stage	
Attachment(s) 1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/0 Paper No(s)/Mail Date/2/15/05.		mary (PTO-413) lail Date mal Patent Application (PTO-152)	

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DETAILED ACTION

Applicant's arguments with respect to claims 1-16 have been considered but are moot in view of the new ground(s) of rejection.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

- (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 1. Claims 1- 16 are rejected under 35 U.S.C. 103(a) as being unpatentable over Manke et al., US Patent No. 6469073 in view of Clere PG Pub 20020006511 and Serhatkulu et al.
- 2. Applicant's invention pertains to a method of delaminating a graphite structure comprising:
 - a. Diffusing a coating agent in a supercritical fluid between layered particles of a graphite structure, wherein the coating agent comprises a polymer
 - i. an oligomer
 - ii. a monomer
 - iii. an oil
 - iv. a mixture of the above

Wherein the supercritical fluid comprises

(1) Carbon dioxide

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(2) Ammonia

- (3) Methane
- (4) Ethane
- (5) Ethylene
- (6) A mixture of the above
- b. Depressurizing the supercritical fluid to form delaminated graphite particles.
- c. Applicant further claims a step for mixing the delaminated particles with a polymer. Suitable graphites include natural graphite, synthetic graphite and expandable graphite.

Delamination is defined as the flaking-off of a coating from the substrate.

Manke et al discloses a method of delaminating a layered silicate to provide improved mechanical properties to select materials such as polymers. The method includes providing particles of the layered silicate and a supercritical fluid. The method further includes contacting the layered silicate particles with the supercritical fluid to define contacted layered silicate particles and catastrophically depressurizing the contacted layered silicate particles to exfoliate the layered particles so that the layered particles are substantially dispersed, defining treated silicate particles. See col. 3, line 26 through col. 5, line 64.

Clere PG Pub 20020006511 discloses that hexagonal boron nitride is an inert, lubricious ceramic material having a plate-like hexagonal crystalline structure (similar to that of graphite). The invention also relates to a method of making delaminated boron nitride powder. This method involves providing boron nitride powder and milling the boron nitride powder in a mixture including a milling media and a milling liquid under conditions effective to produce

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delaminated boron nitride powder. The milling liquid may be water, methanol, ethanol, propanol, butanol, isomers of low molecular weight alcohols, acetone, and <u>supercritical</u> CO₂. In situations in which high aspect ratio h-BN is desired, milling times of between 8 and 48 hours are preferred and the milling temperature is no more than about 30.degree. C.

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Clere has established a delamination process for a particulate inorganic material, (BN), using a milling liquid such as supercritical CO₂. Clere has further established that the BN of his invention possess hexagonal crystalline structure (similar to that of graphite), it would be obvious to one of ordinary skill in the art to utilize a supercritical fluid in a process for delamination graphite. Therefore, the ordinary practitioner in this art would look to Manke et al for a specific process for delamination utilizing a supercritical fluid. See paragraph 12 through paragraph 31.

Serhatkulu teaches a method of delaminating an organically modified clay prior to formation of a polymeric nanocomposite. The process of Serhatkulu relates to the use of CO₂ soluble additives to coat delaminated clay surfaces during supercritical process treatment to prevent the collapse of layered structures after depressurization of carbon dioxide.

It would have been obvious to one of ordinary skill in the art at the time of applicant's invention to utilize the delamination process of Serhatkulu to delaminate other particulate inorganic substances such as graphite. This is supported by Clere which has established a delamination process for a particulate inorganic material, (BN, which has been equated to graphite), using a milling liquid such as supercritical CO₂.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Kriellion A. Sanders whose telephone number is 571-272-1122. The examiner can normally be reached on Monday through Thursday 6:30-7:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Vasu Jagannathan can be reached on 571-272-1119. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Kriellion A. Sanders Primary Examiner

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